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IDS Form PTO/SB/08: Substitute for form 1449A/PITO				Complete if Known		
		( )	10V 2 3 2004	Application Number	10/669,705	
INFORMATION DISCLOSURE			RF	Filing Date	September 25, 2003	
STATEMENT BY APPLICANT TRANS				First Named Inventor	Hao Chen et al.	
STATEMENT BY APPLICABLE TRADE			& TRAD	Art Unit	4614- 1631	
	(Use as many sheets as necessary)			Examiner Name	-not yet known P. WHALEY	
Sheet	1	of	1	Attomey Docket Number	06695.0004-01	

	U.S. PATENTS AND PUBLISHED U.S. PATENT APPLICATIONS						
	Cite	Document Number		Name of Patentee or	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
Initials	No.1	Number-Kind Code <sup>2</sup> (# known)	Publication Date MM-DD-YYYY	Applicant of Cited Document			
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Note: Copies of the U.S. Patent Documents are not Required in IDS filed after October 21, 2004

	FOREIGN PATENT DOCUMENTS					
Examiner Initials	Cite No.	Foreign Patent Document  Country Code <sup>3</sup> Number <sup>4</sup> Kind Code <sup>5</sup> (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	Translation <sup>6</sup>
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NON PATENT LITERATURE DOCUMENTS				
Examiner Initials	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	Translation	
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Examiner Signature	/Pablo Whaley/ (06/16/2006)	Date Considered

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